CO Tip Functionalization Inverts Atomic Force Microscopy
Contrast via Short-Range Electrostatic Forces

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We investigate insulating Cu$_2$N islands grown on Cu(100) by means of combined scanning tunneling microscopy and atomic force microscopy with two vastly different tips: a bare metal tip and a CO-terminated tip. We use scanning tunneling microscopy data as proposed by Choi, Ruggiero, and Gupta to unambiguously identify atomic positions. Atomic force microscopy images taken with the two different tips show an inverted contrast over Cu$_2$N. The observed force contrast can be explained with an electrostatic model, where the two tips have dipole moments of opposite directions. This highlights the importance of short-range electrostatic forces in the formation of atomic contrast on polar surfaces in noncontact atomic force microscopy.

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The combination of scanning tunneling microscopy (STM) with noncontact atomic force microscopy (NC-AFM) in a single probe enables a wide range of atomic-scale studies on surfaces. Whereas contrast mechanisms in STM for different tip-sample systems are widely understood, the interpretation of NC-AFM data remains challenging. In NC-AFM the sum over all tip-sample interactions is measured, and the source of atomic resolution is often hard to identify. On semiconductors [1]—as well as on metals [2]—imaged with reactive tips (e.g., Si) atomic contrast is dominated by the formation of covalent bonds that often reach magnitudes of nanonewtons. For nonreactive CO-functionalized tips, Pauli repulsion was attributed to the observed intramolecular resolution [3,4]. Lantz et al. [5] showed that the dangling bonds of Si(111)-(7×7) can induce a dipole moment in (nonreactive) oxidized Si tips resulting in a short-range electrostatic interaction, which contributes to atomic resolution. Electrostatic interaction and an induced tip dipole moment was also used to explain atomic contrast on ionic crystals [6]. A similar model describes the interaction with charged adatoms on thin insulating layers [7,8]. Moreover, it was found that clean metallic tips carry an intrinsic dipole moment [9,10], which is caused by the Smoluchowski effect [11]. All of these examples underline the importance of atomic-scale electrostatic interactions in NC-AFM.

Electrostatic forces become even more meaningful as polar thin insulating layers (e.g., NaCl, MgO, Cu$_2$N) are used to decouple adsorbates in STM and AFM experiments [3,7,12–16]. In this study we explore the influence of electrostatic forces in NC-AFM on Cu$_2$N islands on Cu(100). N and Cu atoms on Cu$_2$N form a periodic charge arrangement, as calculated by density functional theory (DFT) [17] [Figs. 1(c)–1(e)]. Compared to alkali halides, the Cu$_2$N’s (c/2×2) unit cell structure has a lower symmetry; thus, its atomic positions are easier to designate. STM experiments led to two criteria to locate N atoms within the islands [18]: first, N adsorbs on the hollow sites of Cu(100) [19–21] and should therefore appear fourfold symmetric; second, island boundaries and sharp edges are determined by N atoms [15]. With this, N-, Cu-, and hollow sites can be identified in the Cu$_2$N unit cell [Fig. 1(c)].

In this Letter, we report on high-resolution simultaneously recorded current and force data of the Cu$_2$N surface. We compare interaction forces probed with a

FIG. 1 (color online). (a) Charge redistribution in a metallic tip due to the Smoluchowski effect, leading to an electric dipole moment pointing towards the sample. (b) A CO molecule adsorbed on a copper tip, carrying an electric dipole moment pointing away from the sample. (c) Model of the Cu$_2$N network on Cu(100) with the numbers being the net charge of Cu and N atoms in units of elementary charge $e$ [17]. (d) Cross section of Cu$_2$N along a N-Cu-N row and (e) Cu-hollow site-Cu row showing the first two atomic layers of the reconstructed surface and the net charges of the atoms, respectively. In (c), (d), and (e), larger circles indicate Cu and smaller circles indicate N.
CO-terminated tip to data acquired with a metal tip. The force contrast, though, is inverted. We propose an electrostatic model where the two tips have opposite dipole moments. The calculated force contrast within a Cu$_2$N unit cell provides good agreement to the data.

All experiments were carried out with a home-built low-temperature system at 6 K using a qPlus sensor ($f_0 = 29098$ Hz, $k = 1800$ N m$^{-1}$) [22] equipped with a W tip, operated with small amplitudes (50 pm) in frequency modulation mode. Metallic (Cu) tips were prepared by strongly poking them into a clean Cu sample while applying 200 V. Tips were functionalized with CO molecules following the standard procedure [23]. Cu$_2$N islands were prepared by sputtering a clean Cu(100) crystal with N gas for 120 s and heating it to 600 K for 300 s. Forces were calculated by applying the Sader-Jarvis-deconvolution method [24] to our recorded three-dimensional frequency shift maps.

Figure 2(a) shows a STM topograph of an island using a Cu-terminated tip recorded with a set point of 500 pA at a tip voltage of 10 mV. The image was Laplace filtered and inverted (Laplace filtering inverts brightness) to enhance contrast [15] and a structural model is partially overlaid. The raw data of Fig. 2 can be found in the Supplemental Material [25].

When the Cu tip is terminated by a CO molecule, the STM contrast is different. The constant-current topograph in Fig. 2(d) was recorded using a set point of 100 pA at a tip voltage of 10 mV. Three distinct features appear within the island: elongated protrusions, wide depressions, and—most remarkably—very narrow depressions. It is known that the strong $p$-wave character of CO-terminated tips influences the imaging contrast in STM [26]. In Ref. [26], the authors investigated the organic molecule pentacene, whose orbitals locally exhibit $\sigma$, $\pi$, and $\delta$ symmetry. They used Chen’s derivative rule [27] to explain that due to the CO’s $\pi$ orbital the tunneling matrix element turns to zero over regions where the pentacene’s orbital resembles one with $\sigma$ and $\delta$ symmetries, whereas it does not where the orbital locally has $\pi$ symmetry. We propose a similar tunneling contrast formation for copper nitride, motivated by the DFT calculations of Soon et al. [21]. For the eigenstate closest to our bias voltage of 10 mV, N and Cu atoms show a local $\sigma$ character, in which the N wave function has twice the spatial extension of Cu. Because of the 3$d$ state of Cu and the 2$p$ state of N, the space in between N and Cu shows a local $\pi$ character. Taking into account the N-Cu binding length of 183 pm, which is comparable to atomic distances within pentacene, we argue as follows: N exhibits a local $\sigma$ character and therefore the matrix element concerning the CO’s $\pi$ orbital is zero, resulting in a very confined depression over N. Between N and Cu the CO tip probes a local $\pi$ orbital enabling a tunneling current. Cu also has local $\sigma$ character, but its wave function only extends half as far compared to N. Furthermore, Cu is located 21 pm lower than N [20,21]. From this we conclude that our microscope setup is not able to laterally resolve a depression over Cu as well, resulting in elongated protrusions centered over Cu. For hollow sites, the lateral orbital overlap between tip and sample states is insufficient to yield a nonzero tunneling matrix element, leading to a wide depression. This lattice assignment fulfills the two required assignment criteria [Figs. 2(d)–2(e)].

Figure 2(b) shows the total force for a Cu-terminated tip at closest approach, corresponding to a STM set point of 28 nA at a tip voltage of 10 mV over bare Cu(100). Here, tip-sample distance is defined as the distance between the outermost atomic shells of the involved atoms (see Supplemental Material [25]), in the following called $z_{\text{c-s}}$. [PRL 112, 166102 (2014)]
Using this definition of distance, Fig. 2(b) was measured at \( z_{\text{ss}} = 125 \text{ pm} \) over bare Cu(100).

According to the lattice assignment for metal tips, N sites appear most attractive, followed by Cu sites and hollow sites. The measured overall force is attractive, because of the long-range van der Waals interaction, which normally does not depend on lateral position and thus does not allow for atomic resolution. Subtracting the forces between distinct unit-cell positions cancels out constant long-range interactions and the resulting force contrast contains site-dependent short-range components only. We define \( \Delta F_{\text{N-Cu}} = F_{\text{Ni ss}} - F_{\text{Cu site}} \) and \( \Delta F_{\text{N-hs}} = F_{\text{N site}} - F_{\text{hs}} \) as the force difference (force contrast) between N and Cu sites and between N and hollow sites (hs). Table I shows the averaged force contrast for five different islands probed with different Cu-terminated tips at similar tip-sample distances. The short-range character of the interaction causing atomic contrast is reflected in the \( \Delta F(z) \) curves displayed in Fig. 2(c). The atomic contrast is maintained over a vertical range of about 100 pm.

Figure 2(e) shows the total force at closest approach for a CO-terminated tip, which was at a STM set point of 3 nA at 10 mV over clean Cu(100). To determine the tip-sample distance the above-described model has to be adapted by using the point conductance of a CO molecule on the Cu surface. Experimentally, we find \( G_0 = (404, 497 \Omega)^{-1} \) and \( z_{\text{ss}} = 80 \text{ pm} \) for the closest approach. Figure 2(e) reveals an inverted force contrast compared to Fig. 2(b), with N atoms having the most repulsive interactions and hollow sites the most attractive interactions. The averaged force contrast for three CO-functionalized tips over three different islands at similar tip-sample distances is depicted in Table I. Figure 2(f) displays the above-defined \( \Delta F(z) \) curves, showing repulsive force contrast (i.e., the force difference is positive) for approximately 100 pm.

The AFM images in the center row of Fig. 2 show a contrast inversion for Cu vs CO tips. We attribute this contrast inversion to opposite dipole moments of Cu- vs CO-terminated tips for two reasons. First, Cu-N is a periodic arrangement of charged atoms. The electrostatic potential of such a periodic charge distribution with lattice constant \( a \) decays exponentially [28], with a decay length given by \( \lambda = a/2\pi \) (Cu-N: \( a = 372 \text{ pm} \) [18] and thus \( \lambda = 59 \text{ pm} \)). This small decay length explains the short-range character of this electrostatic interaction [Figs. 2(c) and 2(f)]. Second, in the following we will present an electrostatic model using a point-charge representation of the sample and tip. Using the force contrast and calculated tip-sample distances from the experiment, we fit the tip’s dipole moment to model the experimental force dependence.

From experimental [18] as well as theoretical work [17, 20, 21], the structural parameters and net charges of the Cu-N’s unit-cell atoms are known. The distance between N and Cu is 183 pm, the N atoms are vertically displaced by 21 pm with respect to the Cu surface layer, and the charged subsurface Cu layer has a distance of 197 pm to the Cu surface layer, as indicated in Figs. 1(c)–1(e). Charges were calculated by DFT in Ref. [17] and are \( -1.2e \) for N atoms, \( +0.5e \) for surface Cu atoms, and \( +0.1e \) for the subsurface Cu atoms [Figs. 1(c)–1(e)]. Using these numbers, we constructed a three-dimensional point-charge representation of the sample with a size of \( 7 \times 7 \text{ unit cells} \), including the subsurface Cu atoms, where all charges are located at the atomic-core positions. The resulting electric field was then used to calculate the interaction force with the tip (see Supplemental Material [25]). The Smoluchowski effect [11] causes a charge redistribution on corrugated metal surfaces, which leads to the formation of electric dipoles. For metallic tips, an electric dipole moment is formed pointing towards the sample [9], as depicted in Fig. 1(a). For a CO molecule adsorbed on a metal tip, the electric dipole moment, compared to the gas phase, changes in magnitude and sign due to charge transfer to the metal. We recently found experimental [29, 30] evidence that the CO’s dipole moment is pointing into the metal, as depicted in Fig. 1(b), which is also supported by some ab initio molecular orbital calculations [31]. The tip was modeled as a simple dipole having two charges \( \pm q \) separated by the dipole distance \( d \).

For the Cu-terminated tip, we got the best agreement with a charge of \( \pm 0.13e \) and \( d = 135 \text{ pm} \) (close to the atomic radius of Cu) resulting in a dipole moment of \( 0.182e\text{Å} = 0.874 \text{ D} \). The dipole points towards the sample, as described before, where the positive charge is located at the core of the front-most Cu tip atom. For the calculation, the positive tip charge (Cu core) was placed at a distance of 395 pm above the charges (cores) of the Cu surface layer. This distance was obtained by adding twice the atomic radius of Cu to the experimental \( z_{\text{ss}} = 125 \text{ pm} \) (see Supplemental Material [25]). Figure 3(b) shows the calculated force between this metal tip dipole and all surface atoms. The force above the Cu site was set to zero.

### Table I. Comparison of averaged experimental and simulated force contrast for Cu- and CO-terminated tips.

<table>
<thead>
<tr>
<th>Tip Type</th>
<th>Experiment $\Delta F_{\text{N-Cu}}$</th>
<th>Simulation</th>
<th>Experiment $\Delta F_{\text{N-hs}}$</th>
<th>Simulation</th>
</tr>
</thead>
<tbody>
<tr>
<td>Cu tip</td>
<td>$(-10 \pm 2) \text{ pN}$</td>
<td>$-12 \text{ pN}$</td>
<td>$(-17 \pm 3) \text{ pN}$</td>
<td>$-17 \text{ pN}$</td>
</tr>
<tr>
<td>CO tip</td>
<td>$(22 \pm 1) \text{ pN}$</td>
<td>$26 \text{ pN}$</td>
<td>$(39 \pm 2) \text{ pN}$</td>
<td>$34 \text{ pN}$</td>
</tr>
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to emphasize the force contrast. Line profiles along the N-Cu-N and Cu-hollow site-Cu directions from Fig. 3(b) are plotted in Fig. 3(c) (dash-dotted line and dash-dot-dotted line). The relative interaction contrast is given in Table I and fits well to the experimental results. To compare the simulation to the experiment, Fig. 3(a) shows a zoom-in of the island in Fig. 2(b) (unit-cell average over the inner part plus $3 \times 3$ Gauss filter) with the respective line profiles shown in Fig. 3(c) (solid line and dashed line).

In conclusion, we have shown that atomic resolution on relatively inert surfaces such as Cu$_2$N can be obtained by electrostatic multipole forces and not just by covalent bonding forces or Pauli repulsion forces. Richard Feynman already pointed out in his 1939 paper [33] that the force on a nucleus in an atomic system ultimately has an electrostatic origin. The difference we observed here compared to the covalent case in atomic imaging of semiconductors is that covalent bonds usually result in massive rearrangements of electronic charge density and subsequently forces in the nanonewton regime, while the forces here are only tens of piconewtons with much less redistribution of electronic charge.

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[25] See Supplemental Material at http://link.aps.org/supplemental/10.1103/PhysRevLett.112.166102 for the calculation of the tip-sample distance for metal tips, an estimation of the error in the calculated tip-sample distance for metal tips, a determination of the tip-sample distance for CO-terminated tips, details for the electrostatic simulation, the raw data of Fig. 2, the frequency shift and force vs distance spectra, and experimental uncertainties in the force measurement.